Effect of Dopant Concentration on Structural and Optical Properties of Cu Doped SnO₂

Gurwinder Pal Singh, Navneet Kaur, Abhinav, Sacheen Kumar and Dinesh Kumar

Abstract Now a day, nanomaterial plays important role in every field due to their unique properties which are completely different from the bulk materials. Material Properties are dynamically changed with reduction in the crystallite size. Transparent conducting oxides (TCOs) are optically transparent to visible light, but electronically conductive. Owing to these properties, they have broad industrial applications such as optoelectronic devices and photovoltaics. Doped Tin Oxide is an oxygen deficient material which could be beneficial for transparent conducting oxide. The SnO₂ was doped with Cu as a dopant element at different concentration. Mede-A software for material design was used to obtain the theoretical data which is to be compared with the practical results. Co-precipitation method was used to prepare Cu-doped SnO₂. Studies on structural properties of undoped and doped SnO₂ were done by X-ray diffraction. The XRD results have shown that the size of the nanoparticles decreases down to 51 nm with increase in dopant concentration. Optical Properties were studied by UV-visible spectroscopy. Band gap was found to decreases down to 2.25 eV with increase of dopant content in samples.

1 Introduction

In the recent time nanoparticle plays important role in every field, due to their unique mechanical, chemical and electrical properties which are completely different from the bulk material. Semiconductor materials are widely used in electronic devices but in the field of optoelectronic these materials have some limitations. To overcome these limitations metal oxides are used. Transparent conducting oxides (TCOs) are electronically conductive and optically transparent to visible light. Due to these properties, they are extensively used in industrial applications such as optoelectronic devices and photovoltaics [1]. Transparent conductive oxide thin

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film of ITO, SnO₂ and ZnO are widely used in the field of optoelectronic such as transparent electrode in touch panel, flat panel displays and OLED (Organic light emitting diode). Successful performance of these applications depends on a combination of good transparency and low resistivity of TCOs, mostly achieved by controlling chemical compositions of wide band-gap semiconducting materials with various doping agents [2]. Now a days ITO is most widely used material for TCO. SnO₂ is used in gas sensor, solar cell, display devices and other optoelectronic application. Indium is replaced by low cost and easily available material such as Cu. The electrical conductivity of SnO₂ is increased with introducing the foreign doping element [3]. SnO_2 has a rutile crystal structure in which Sn atoms are present at each corner and are surrounded by oxygen atoms. Doping can cause the impurity atoms to either replace Tin atoms or occupy the void space. The SnO₂ nanoparticle are prepared by using different method such as CVD, sol-gel, co-precipitation and thermal evaporation method [4]. Among the different methods for the doped and un-doped SnO_2 (multi-component TCO) production the co-precipitation method is the most useful method for mass production [5]. In the present work we have investigated the optical and structural properties of Cu doped SnO₂ and results are compared with the theoretical data obtained from the material design software Mede-A. For SnO₂ structural conformation and particle size calculation X-ray diffraction (XRD) is used. Doping of Cu in SnO₂ at different concentration is done to analyze the changes in band gap, conductivity and optical transmittance.

2 **Experimental Details**

Modelling

VASP 5.3 module of Mede-A was used to observe the structural and optical properties of undoped and doped SnO_2 .

Figure 1 represent the designed model of undoped SnO_2 by material design software Mede-A in which there are 2 atoms of Sn are present and 4 atoms of oxygen are there and Fig. 2. Represent the designed model of Cu-doped SnO_2 using Mede-A in which 1 Cu atom is present, 15 Sn atoms and 32 atoms of oxygen are present.

Materials Used

The material used to synthesize Undoped and doped SnO_2 nanoparticles are Stannous Chloride Dihydrates ($SnCl_2.2H_2O$), Sodium Hydroxide (NaOH) and Cupric Chloride Dihydrate (CuCl_2.2H_2O). $SnCl_2.2H_2O$ was used as precursor to synthesized SnO_2 nanoparticles and NaOH was used as reducing agent. The CuCl_2.2H_2O and FeCl_3 are the dopant materials. All the chemicals were used of Loba Chemie with high purity.

Synthesis Procedure

See Fig. 3.

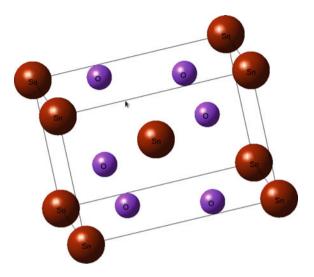


Fig. 1 Undoped SnO_2 model by Mede-A

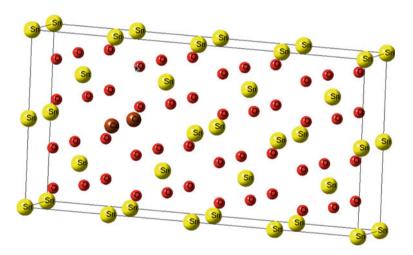
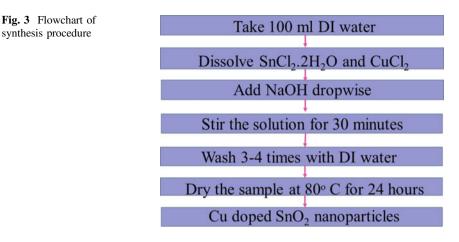


Fig. 2 Cu-doped SnO_2 model by Mede-A



3 Results and Discussion

Structural Properties

Structural properties are determined by the XRD pattern of all the prepared SnO₂ nanoparticles. XRD Results obtained from Mede-A are compared with the practical data of sample.

Scherrer formula is used to calculate the crystallite size using the following equation,

$$d = 0.91\lambda/\beta \cos \theta$$

where d is the crystallite size, λ is the wavelength of X-ray used, and θ is the Bragg angle of diffraction peaks. Figure 4 shows the XRD patterns of all the samples and Intense diffraction peaks of the SnO₂ were observed at 29.82°, 33.705°, 45.454° and 56.474° which were indexed to the (110), (101), (200) and (220) planes, respectively, up to 10 % of Cu doping. It is evident from XRD patterns that SnO₂ has rutile type structure with Sn at octahedral site and O at tetragonal site. The results show that as doping increases the crystalline size decreases.

Optical Properties

The reflection spectra in the UV-VIS range of SnO_2 : Cu nanoparticles with 6 % Cu concentrations are presented in Fig. 5 The optical band gap (E_g) for Cu-doped SnO_2 nanoparticles can be determined by extrapolation from the absorption edge which is given by the following equation:

$$(\alpha h v)^2 = A(h v - E_g)$$

where A is a constant and hv is the photon energy. Cu doped SnO_2 powders showed optical band gap decrease from 3.17 down to 2.25 eV when the Cu concentration increased up to 10 %. This result was compared with the Mede-A results as shown in Fig. 6.

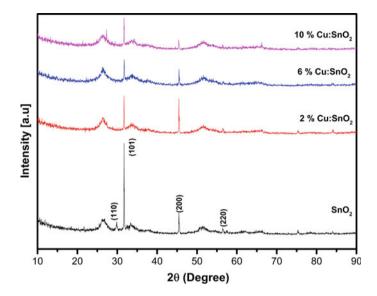


Fig. 4 XRD spectra of undoped SnO_2 and Cu-doped SnO_2

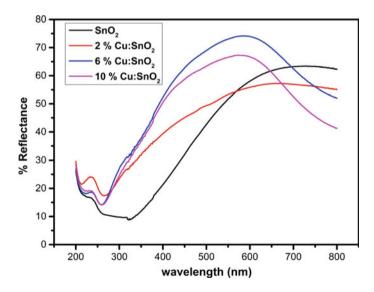


Fig. 5 UV-Vis spectra of undoped and Cu doped-SnO $_2$ nanoparticles

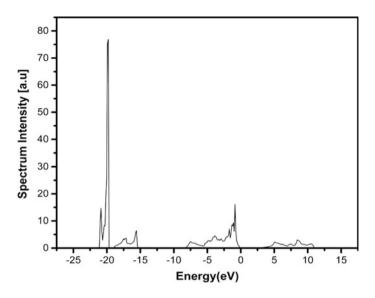


Fig. 6 Shows the calculated density of states of pure SnO2 by material design software Mede-A

The density of states (DOS) of a system describes the number of states per interval of energy at each energy level that are available to be occupied. Unlike isolated systems, like atoms or molecules in gas phase, the density distributions are not discrete like a spectral density but continuous. A high DOS at a specific energy level means that there are many states available for occupation. A DOS of zero means that no states can be occupied at that energy level. In general, a DOS is an average over the space and time domains occupied by the system. The graph is plotted between the intensity and energy.

Table 1 shows the Bandgap and crystal size of the pure SnO_2 and Cu doped SnO_2 . The Cu is doped in SnO_2 at different concentration. When the doping concentration of Cu is increased the crystal size is decrease from 90 to 51.46 nm. As well as with decreasing the crystal size the bandgap is also reduced from 3.17 to 2.25 eV. At lower doping concentration (2 %) of Cu there was an unexpected increment in the band gap from 3.17 to 4.49 eV. But when the doping concentration of Cu is increased from 2 to 6 and 10 % the band gap is decreased to 2.25 eV that is lower than pure SnO_2 . It means with increasing the concentration of Cu in SnO_2 the conductivity is increased due to decreasing the Bandgap.

Table 1 Shows the crystal
size and bandgap of pure
SnO_2 and Cu doped SnO_2

Material	Bandgap (eV)	Crystallite size (nm)
Undoped SnO ₂	3.17	90
SnO ₂ : Cu 2 %	4.49	75.83
SnO ₂ : Cu 6 %	2.34	66.49
SnO ₂ : Cu 10 %	2.25	51.46

4 Conclusions

In this study, Cu-doped SnO_2 nanoparticles were prepared by co-precipitation method. From UV-Vis spectroscopy it is found that the band gap of Cu doped SnO_2 shows a decrease from 3.17 to 2.25 eV with the Cu concentration increase up to 10 %. The XRD analysis revealed that the crystallites have the expected SnO_2 tetragonal phase and crystallite size reduces with Cu doping up to 10 mol% down to 51 nm.

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